



H3D02120L

Silicon Carbide Schottky Diode Chip

V_{RRM}	=	1200	V
$I_{F(AVG)}$	=	2	A
Q_c	=	8	nC

Features

- 1200-Volt Schottky Rectifier
- Zero Reverse Recovery
- Zero Forward Recovery
- Positive Temperature Coefficient on V_F
- Temperature-Independent Switching Behavior

Chip Outline



Part Number	Die Size	Anode	Cathode
H3D02120L	1.21x1.21 mm ²	Al	Ni/Ag

Maximum Ratings

Symbol	Parameter	Value	Unit	Test Conditions	Note
V_{RRM}	Repetitive Peak Reverse Voltage	1200	V		
V_{DC}	DC Blocking Voltage	1200	V		
$I_{F(AVG)}$	Average Forward Current	2	A	$T_c \leq 164^\circ C$	1
I_{FSM}	Non-Repetitive Forward Surge Current	20	A	$T_c = 25^\circ C, t_p = 8.3ms, \text{Half Sine Wave}$	1
T_J	Operating Junction Temperature	-55 to 175	°C		

1. Assumes Thermal Resistance of 2.5°C/W or less

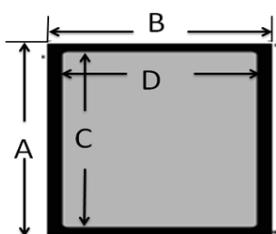
Electrical Characteristics

Symbol	Parameter	Typ.	Max.	Unit	Test Conditions	Note
V _F	Forward Voltage	1.55 2.2	1.8 2.5	V	I _F = 2A, T _J = 25°C I _F = 2A, T _J = 175°C	Fig.1
I _R	Reverse Current	2 10	20 200	µA	V _R = 1200V, T _J = 25°C V _R = 1200V, T _J = 175°C	Fig.2
C	Total Capacitance	135 10 8	/	pF	V _R = 0V, T _J = 25°C, f = 1MHz V _R = 400V, T _J = 25°C, f = 1MHz V _R = 800V, T _J = 25°C, f = 1MHz	Fig.3
Q _C	Total Capacitive Charge	8	/	nC	V _R = 800V, I _F = 2A di/dt = 200A/µs, T _J = 25°C	Fig.4

Mechanical Parameters

Parameter	Typ.	Unit
Die Size	1.21x1.21	mm ²
Anode Pad Opening	0.72x0.72	mm ²
Thickness	350±50	µm
Wafer Size	100	mm
Anode Metallization (Al)	4	µm
Cathode Metallization (Ni/Ag)	1.6	µm
Frontside Passivation	Polyimide	

Chip Dimensions



Symbol	Dimension
A	1.21mm
B	1.21mm
C	0.72mm
D	0.72mm

Typical Performance

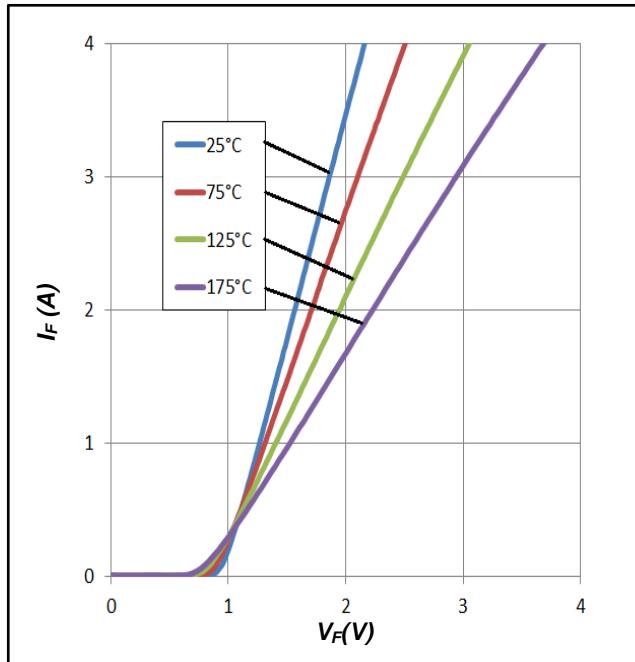


Figure 1. Forward Characteristics

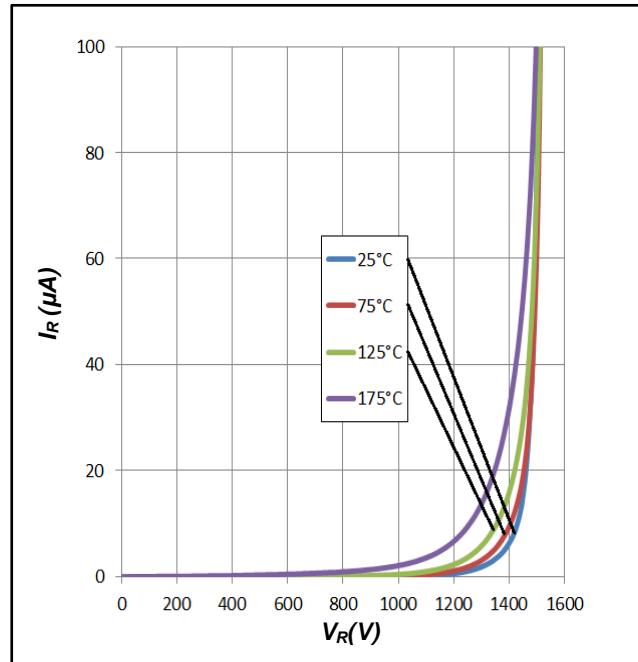


Figure 2. Reverse Characteristics

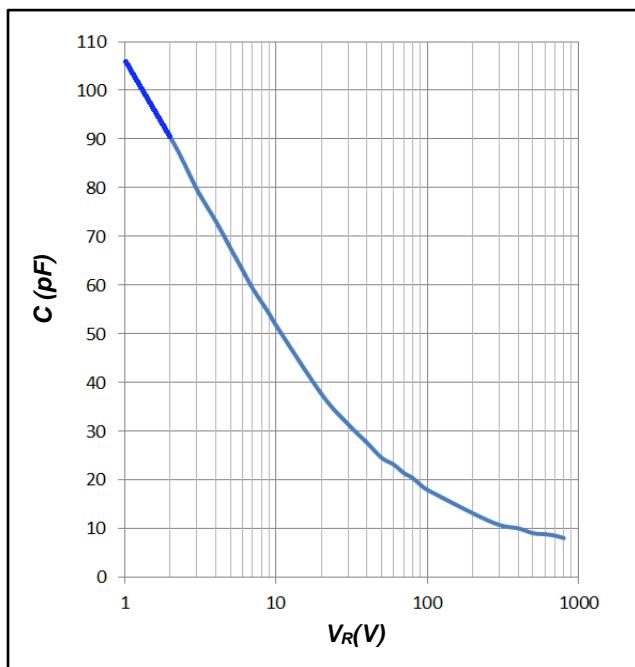


Figure 3. Total Capacitance vs. Reverse Voltage

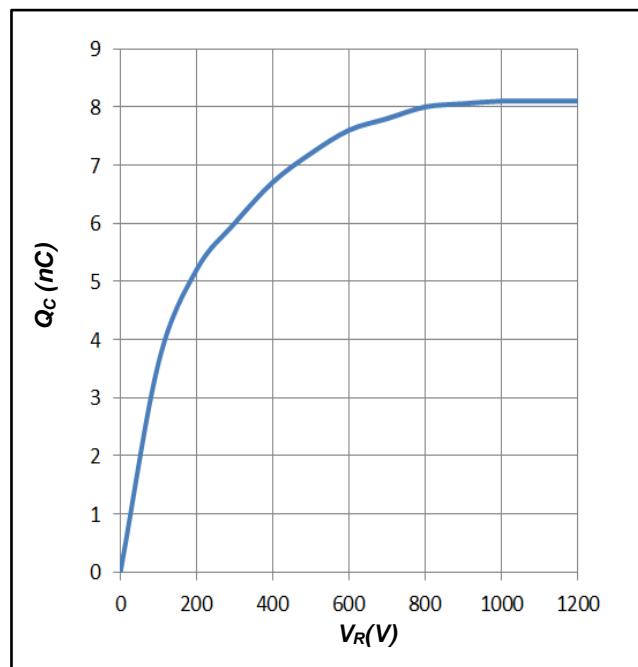


Figure 4. Total Capacitance Charge vs. Reverse Voltage